

9/6/02
#20/EUT
(HMC)
Patent

Attorney's Docket No. 027260-295

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Kazuya KAMON

Application No.: 09/320,946

Filed: May 26, 1999

For: PHOTOMASK, FABRICATION
METHOD OF PHOTOMASK, AND
FABRICATION METHOD OF
SEMICONDUCTOR INTEGRATED
CIRCUIT



Group Art Unit: 1756

Examiner: S. Mohamedulla

Confirmation No.: 5858

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PETITION FOR EXTENSION OF TIME

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

The following extension of time is requested to respond to Notice of Appeal dated June 3,
2002 :

one month to September 3, 2002 ; the extension fee is:

[] \$55.00 (215) [X] \$110.00 (115).

[] The shortened statutory period has been reset by an Advisory Action dated

[X] An extension fee in the amount of \$ 110.00 is enclosed.

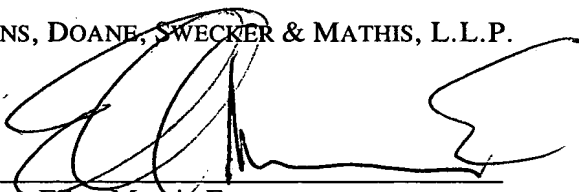
[] Charge \$ _____ to Deposit Account No. 02-4800.

The Commissioner is hereby authorized to charge any appropriate fees under 37 C.F.R.
§§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to
Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,

BURNS, DOANE, SWECKER & MATHIS, L.L.P.

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110.00 OP

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Date: September 3, 2002